# D ivergent resistance at the D irac point in graphene: Evidence for a transition in a high magnetic eld

Joseph G. Checkelsky, Lu Li and N. P. Ong

Department of Physics, Princeton University, Princeton, NJ 08544, USA

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We have investigated the behavior of the resistance of graphene at the n = 0 Landau Level in an intense magnetic eld H. Employing a low-dissipation technique (with power P < 3 fW), we nd that, at low temperature T, the resistance at the D irac point R<sub>0</sub> (H) undergoes a 1000-fold increase from 10 k to 40 M within a narrow interval of eld. The abruptness of the increase suggests that a transition to an insulating, ordered state occurs at the critical eld H<sub>c</sub>. Results from 5 sam ples show that H<sub>c</sub> depends system atically on the disorder, as measured by the o set gate voltage V<sub>0</sub>. Sam ples with small V<sub>0</sub> display a smaller critical eld H<sub>c</sub>. Empirically, the steep increase in R<sub>0</sub> ts acccurately a K osterlitz-T houless-type correlation length over 3 decades. The curves of R<sub>0</sub> vs. T at xed H approach the therm al-activation form with a gap 15 K as H ! H<sub>c</sub>, consistent with a eld-induced insulating state.

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### I. IN TRODUCTION

In graphene, the low energy states display a linear energy-momentum dispersion described by the Dirac H am iltonian. The observation of the integer quantum H all (Q H) e ect by N ovoselov et al. [1, 2, 3] and Zhang et al. [4, 5, 6] has sparked intense interest in this novel 2D (two-dimensional) system. In a strong magnetic eld H, the states are quantized into Landau Levels. As a result of the D irac dispersion, the energy  $E_n$  of the Landau Level (LL) (of index n) increases with the ux density B as  $\overline{B}$ , viz.  $E_n = \text{sgn}(n) \quad \overline{2e} - v_F^2 B$  jn j where  $v_F$  is the Ferm i velocity, e the electron charge, and h is P lanck's constant. The H all conductivity is observed to be accurately quantized as  $x_y = (4e^2 = h) [h + \frac{1}{2}] = e^2 = h$ , where e is the electron charge, 2 ~ is P lanck's constant, and

the sublevel index. A key question is the nature of the ground state at the D irac point. In intense H, theory predicts interesting broken-symmetry states driven by exchange and interaction. These are characterized as quantum H allFerrom agnetism (QHF) [7,8,9,10,11,12], or excitonic condensation [13, 14, 15, 16]. These collective states in ply the existence of ekd-induced phase transitions, but the experimental situation is rather unsettled. M oreover, the proposed [12, 17, 18] existence of counter-propagating edge m odes at the D irac point has further enriched the theoretical debate. Is the high-eld D irac point a QH insulator or a QH m etal?

Recently, we reported [19] that the resistance at the D irac point R<sub>0</sub> begins to increase steeply at B = 10-12 T, suggesting a transition to an insulating state. However, the results left open several key questions. Because R<sub>0</sub> increased by only 1-decade (to 0.2 M) [19], we could not establish that the high- eld state is truly insulating. In graphene, the extrem e sensitivity to therm al runaw ay has been highly problem atical for researching its high-H ground state [5, 6, 19]. Adopting a low-dissipation technique to avoid self-heating, we have measured the divergence in R<sub>0</sub> to 40 M ( 1500 h=e<sup>2</sup>) in 3 sam ples.

Remarkably, the divergence is accurately described over 3 decades by the K osterlitz-Thouless (KT) correlation length. The singular nature of the divergence provides strong evidence that a 2D transition to an insulating state occurs when B exceeds a critical eld H  $_{\rm c}$ . The system atic variation of H  $_{\rm c}$  with  ${\rm j}V_0$  j (the gate voltage needed to bring the chemical potential to the D irac point) in plies that disorder is very elective in delaying H  $_{\rm c}$  to higher eld values. In all samples investigated to date, the transition to the insulating state is reached in elds below 35 T.

### II. EXPERIMENTAL DETAILS

Empirically, problems associated with self-heating in graphene becom e serious when the power dissipated P exceeds 10 pW for bath tem perature  $T_b < 1 \text{ K}$ . As discussed in the Appendix, self-heating below 1 K leads to a num ber of spurious features caused by therm al instability in the sam ple. We adopted a sim ple voltage-controlled technique with ultra-low dissipation that avoids this difculty, and allows the divergence in  $R_0$  to be measured reliably to 40 M . An ac source maintains a xed voltage am plitude (40 V) across the sam ple in series with a 100-k resistor (details are given in the Appendix). By phase-sensitive detection of both the current I and the voltage  $V_{xx}$ , we have m ade 4-probe m easurem ents of R  $_0$ with ultra-low dissipation (P decreases from 3fW at 10 T to 40 aW above 25 T). Moreover, for T < 1.5 K, the sam ple is immersed in liquid <sup>3</sup>H e so that the electrons in graphene are in direct contact with the bath. The largest reliably-measured  $R_0$  is now 40 M (lim ited by the input im pedance 100 M of the pream plier). The new results provide an enlarged view of the interesting region in which R<sub>0</sub> diverges. The sam ples K 52 and J24 have o set voltages  $V_0$  much larger than that in K 7, the sample investigated in detail in Ref. [19]. All sam ples except J18 were measured as-fabricated. Sam ple J18 was subject to a  $\frac{1}{2}$  hr. anneal in He gas at 80 C which decreased V<sub>0</sub> to

8~V . However its large H  $_{\rm c}$  suggests that its initial value of  $V_0$  (before annealing) is very large.

In Sam ples K 52, J18 and J24, the spacings a between voltage leads are 3.5, 2.75 and 3 m, while the widths w are 3, 3 and 2 m, respectively.



FIG.1: (color online) (M ain Panel) D ivergence of the resistance  $R_0$  at the D irac point with B at T = 0.3, 1.5, 5 and 27 K (Sam ple K 52). At 27 K, the increase in  $R_0$  is quite m oderate (to 190 k at H = 31 T). At T = 0.3 K, how ever,  $R_0$  exceeds 20 M above 27 T. The curves at 0.3 and 1.5 K undergo a 1000-fold increase (40 k to 40 M ) in the narrow eld interval 17-27 T. In high B, the 5 K curve deviates signicantly from them. The inset shows the behavior of  $R_0$  vs. H in greatly expanded scale (100). The voltage-regulated technique used for these m easurements dissipates 3 fW at 10 T and 40 aW above 25 T.

## III. FIELD DEPENDENCE OF $R_0$

Figure 1 (m ain panel) show sources of R<sub>0</sub> vs. H in K 52 at tem peratures T = 0.3 to 27 K. A servicent in the curves at 0.3 and 1.5 K, R<sub>0</sub> undergoes a very steep, divergent increase when H exceeds 25 T. The region just before the divergence occurs is shown in greatly expanded scale in the inset. At 27 K, the increase in R<sub>0</sub> is relatively m odest (20) between B = 0 and 31 T (inset). How ever, as T decreases to 5 K, the increase steepens sharply, as reported [19] for K7. Further cooling from 5 to 0.3 K changes the pro le only very slightly. In the main panel, the curves at 0.3 and 1.5 K (which cannot be distinguished) show that  $R_0$  diverges to 40 M , with a slope that steepens rapidly with H . The 3-decade increase (40 k ! 40 M ) occurs within the narrow interval 17{27 T.We nd that the observed divergence is too steep to tapower-law of the kind  $R_0$  (H  $_{\rm c}$  H) , with > 0 and H  $_{\rm c}$  a critical eld.



FIG.2: (color online) P lot of R<sub>0</sub> vs. 1 = 1 h for Sam ples K 52, J18 and J24 at T = 0.3 K, where h = H = H<sub>c</sub> (the curve for K 52 is displaced by 1 decade for clarity). R<sub>0</sub> is expressed as sheet resistance (=). For each sam ple, H<sub>c</sub> is the optimal value that gives the best straight-line t vs. 1 = 1 h (curvature is noticeable if H<sub>c</sub> is altered by 0.1 T from this value). For Sam ples K 52, J18 and J24, H<sub>c</sub> equals 29.1, 32.1 and 35.5 T, respectively. For K52, the thin solid line is the expression R (h) = 440 exp [2b=1 h], with b = 1.54. The data m atch R (h) very well over nearly 3 decades in R<sub>0</sub>.

As in Ref. [19], we compare the divergence with that predicted for the K osterlitz-T houless (KT) transition. In 2D systems described by the XY model, the ordered phase is destroyed at the KT transition by unbinding of pairs of topological excitations (e.g. vortices). As the transition here is induced by varying the applied eld H, we replace the reduced temperature t by the reduced eld  $h = H = H_c$ , with  $H_c$  the critical eld. In the limit h ! 1, the KT correlation length diverges as

$$= a \exp \left[ b = \frac{p}{1 + h} \right]; \tag{1}$$

where a is the lattice parameter and b a number 1.

The quality of the t to Eq. 1 is best revealed in a plot of  $\log R_0$  vs. the quantity 1=1 h. In Fig. 2,

we have plotted  $\log R_0$  in 3 sam ples K 52, J19 and J24 against 1=1 h. In each sam ple, the value of  $H_c$  is adjusted to maxim ize the high-eld portion of the plot that falls on a straight line (this is the only adjustment m ade). In Sam ples K 52, J18 and J24, the inferred values of  $H_c$  are 29.1, 32.1 and 35.5 T, respectively. The values of  $R_0$  in K 52 t the straight line representing the expression R (h) = 440 exp [2b=1 h], with  $H_c = 29.1$  T and b = 1.54. The value of b is consistent with the K T transition. The 3-decade span is strong evidence that Eq. 1 accurately describes the divergence in  $R_0$ , and supports the inference that, at low T, we are observing a 2D K Ttype phase transition to a high-eld ordered state that is insulating.



FIG. 3: (color online) C om parison of the curves of  $R_0$  vs. H at 0.3 K in log-log scale in 5 sam ples K7, K22, K52, J18 and J24 with gate voltage o sets  $V_0$  = 1, -0.6, 3, 20, { and 24 V, respectively ( $V_0$  before annealing is not known in J18).  $R_0$  is expressed as sheet resistance = . In K7 and K22 (which have sm all  $jV_0$ ), the divergence in  $R_0$  occurs at a lower H [19]. The fem towatt-dissipation technique applied to K52, J18 and J24 was not available for K7 and K22 (their curves were lim ited to  $R_0 < 0.3\,M$ ). The dashed curve is the t of the K52 data to R .

The signi cant spread of H  $_{\rm c}$  inferred from the ts in Fig. 2 is in accord with Ref. [19] which reported that H  $_{\rm c}$  correlates with the o set voltage V<sub>0</sub>. In Fig. 2, the sam ples K 52, J18 and J24 display a much larger critical eld H  $_{\rm c}$  than the sam ple K 7 (with V<sub>0</sub> = 1 V and H  $_{\rm c}$  = 18 T) studied in detail in Ref. [19]. Figure 3 plots together, in log-log scale, the curves of R  $_0$  vs. H in the 5 sam ples for which we have detailed high- eld transport results. The system atic shift to higher elds of the divergence (in the order K 22, K 7, K 52 and J24) is matched by the increase in their V<sub>0</sub> (-0.5, 1, 3, 20 and 24 V, respectively). The value of V<sub>0</sub> before annealing in J18 is not know n. The dependence of H  $_{\rm c}$  on V<sub>0</sub> is non-linear. Initially (for 0 < V<sub>0</sub> < 4V), H  $_{\rm c}$  increases rapidly, but appears to increase rather slow ly when V<sub>0</sub> exceeds 20 V.

From a study of how  $V_0$  a ects the zero-eld transport,

we have obtained evidence that the zero-eld m obility e is strongly suppressed if  $V_0$  is large. In F ig. 4, we display curves of  $R_{xx}$  vs. the unshifted gate voltage  $V_q$  in a batch of sam ples that includes K 22. The curves are taken at 295 K or 4 K (as indicated). In each sample, the width  $V_{q}$ of the peak at the D irac point directly measures 1 = e. C learly, the width increases dram atically with V<sub>0</sub>. These results support the inference that a large o set  $V_0$  gives rise to large electronic disorder which enhances disorder scattering and suppresses e. In turn, in an intense eld, the transition eld H c is pushed to higher values. W hile these correlations do not exclude other factors that may in uence H  $_{\rm c}$ , we have found that V $_0$  is the single most reliable predictor of the eld scale at which the divergence onsets at low T.



FIG. 4: Curves of the longitudinal resistance  $R_{\rm xx}$  vs. unshifted gate voltage  $V_g$  in zero-H in a series of samples at 295 K and 4 K (as indicated). The width of the peak in  $R_{\rm xx}$  increases system atically with  $V_0$  (located by the peak position). This implies that the mobility  $_e$  is very low in samples with large  $V_0$ .

## IV. DOPING DEPENDENCE

Further insight into the nature of the divergence is obtained by viewing the behavior of the longitudinal resistance  $R_{xx}$  vs.  $V_g$  in a narrow gate window around the Dirac point at xed B (with T kept at 0.3 K). Figure 5a displays a series of curves of R  $_{\rm xx}$  (in log scale) vs.  $V_{\rm q}$  in K52 for elds 10 H 31 T.At 10 T, R<sub>xx</sub> displays 3 well-separated peaks corresponding to n = 0 LL at 20 V and the n = 1 LL's at 6 and 38 V, respectively. For 20 T, the n = 1 levelsm ove out of the gate-voltage Η window. We focus on the divergent enhancem ent of the central peak as B increases to 31 T. The key feature is that  $R_{xx}$  at the D irac point ( $V_q = 20 \text{ V}$ ) rises most rapidly especially for B > 25 T.



FIG.5: (color online) Variation of  $R_{xx}$  (Sam ple K 52) vs. the gate voltage  $V_g$  in the interval (0<  $V_g$  < 38 V), with B xed at selected values 10{31 T, and T = 0.3 K (Panela). At B = 10 T, the central peak (n = 0 LL) is well separated from the LL peaks labelled as n = 1. At B = 20 T and higher, the n =

 $1 \ {\rm LL}$ 's fall outside the gate w indow . W ith increasing B, the central peak increases rapidly and broadens. At them axim um B (31 T),  $R_{xx}$  at the D irac point ( $V_g$  = 20 V) diverges to values above 40 M . The voltage-regulated technique has poor resolution when  $R_{xx}$  falls below 0.3 k . Panel (b) show s the contour plot of  $R_{xx}$  ( $n_{2D}$  ;B) at 0.3 K in the  $n_{2D}$  {B plane (color bar of  $R_{xx}$  shown on right). The dashed lines trace the sublevel degeneracy 1=2  ${}^{2}_{B}$ . The density is given by  $n_{2D}$  = C  $V_g$ =A e where C and A are the capacitance and area of the device, respectively (C=A = 1:14  $10^{-4} \ {\rm Fm}^{-2}$ ).

It is instructive to view R<sub>xx</sub> (at 0.3 K) as a contour plot in the n<sub>2D</sub> {B plane where n<sub>2D</sub> is the 2D density of carriers doped by gating (Fig. 5b). The colorbar (right) gives the magnitude of R<sub>xx</sub>. Interestingly, the steep increase in R<sub>xx</sub> with B is conned to the region between the dashed lines, which trace the sublevel degeneracy 1=2  $\binom{2}{B}$ . This suggests that only the states within the lowest sublevels (on either side of = 0) are a ected by the opening of the gap. The contours appear to converge to a rounded cusp at n<sub>2D</sub> = 0, but with a curvature that increases rapidly with B. At the largest R<sub>xx</sub> (white region), the contour resembles a a narrow, sharp wedge. The contour pattern suggests that H<sub>c</sub> increases very rapidly from the value 29.1 T, as  $j_{2D}$  jdeviates from 0.

The physical picture in plied by the results is that, at the D irac point, a eld-induced transition to a gapped, insulating state occurs at  $H_c$ . The value of  $H_c$  is highly



FIG. 6: (color online) The T dependence of  $R_0$  in Sample J18 with H xed at selected values in the interavl20< H < 31.2 T.As H approaches  $H_c$  (32.1 T),  $R_0$  approaches the therm ally activated form  $e^{-T}$ . The thin dashed curves are ts to this form with the gap = 12.9 and 14.7 K at H = 30 and 31.2 T, respectively. At the highest eld (31.2 T),  $R_0$  increases by a factor of 310 between 16 and 2 K.

sensitive to slight deviations away from exact charge neutrality (Fig. 5). As we decrease H below H $_{\rm c}$ , the ordered state is unstable to the spontaneous unbinding of (vortex-like) topological excitations which have a m can spacing of

(Eq. 1). Because  $R_0$  ts accurately to <sup>2</sup> over 3 decades, we infer that the conductance scales as the density of excitations. Hence the excitations are charged, and they carry the entire current I in the lim it T ! 0. As this conduction channel is qualitatively distinct from therm ally activated carriers, it m ay account for the unusual \saturation" behavior of  $R_0$  vs. T [19]. As T ! 0, with H xed near H c, the conduction crosses over at 1 K from a steep, them ally activated channel to a T-independent channel carried by the excitations (Fig. 1b).

### V. TEM PERATURE DEPENDENCE

The T dependence of R<sub>0</sub> in J18 with H xed at selected values is displayed in sem ilog scale in Fig. 6. At the relatively high eld H = 20 T, the 2-fold increase in  $R_0$ between 16 and 2 K is quite m odest. How ever, above 20 T, the T dependence steepens rapidly. As H is increased towards the critical H<sub>c</sub> (= 32.1 T), the pro le of R<sub>0</sub> m oves e  $^{=\mathrm{T}}$  . W e have ever closer to the activated form  $R_0$ plotted ts to the activated form (dashed curves) at the 2 highest elds H = 30 and 31.2 T.At the highest H, the m easured R<sub>0</sub> tracks closely the dashed curve until T falls below 3 K where it deviates downwards. As H decreases further from H<sub>c</sub>, the deviations start at a higher T. The gap value equals 12.9 and 14.7 K at 30 and 31.2 T, respectively. The latter provides an estim ate of the energy gap in the ordered state for J18. Establishing that  $R_0$  is therm ally activated when H > H  $_{\rm c}$  is an essential goal, as it shows that the ground state above H  $_{\rm c}$  is a true insulator with a well-de ned gap order parameter (as opposed to a state in which the carriers are strongly localized). A lthough the curves in Fig. 6 come close to establishing this result, measurements of R  $_0$  vs. T in samples with more accessible H  $_c$  are desirable.

Interestingly, throughout the pre-transition region (20 < H < H<sub>c</sub>), R<sub>0</sub> also displays large increases with decreasing T. The carriers are strongly a ected by the impending insulating state. We interpret these changes as re ecting very strong uctuations in the order parameter that characterizes the ordered insulating phase. The strong T dependence is also apparent in the xed-T curves shown in Fig. 1.

Q uite apart from the therm al activation argument, there are other evidence to suggest that the divergence is not consistent with electron localization. As evident from m easuring the widths of the peaks of  $R_{xx}$  vs.  $V_g$  taken in zero B, samples with smallest  $jV_0$  jare the least disordered. The electron mobility  $_e$  decreases from 2.5 to 0.5 T  $^1$  as  $jV_0$  j increases from 0.5 to 20 V.W ith this trend in m ind, we compare in Fig. 3 the pro les of  $R_0$  vs. B in K52 with K7 and K22 [19]. In Samples K22 and K7 (with  $V_0 = -0.6$  and 1 V, respectively), the divergence in  $R_0$  is apparent in relatively low B (below 12 T). By contrast, we must go to much higher elds (> 20 T) in K 52. The dashed line is the t to R in K 52 (H > 18 T) described above.

In the localization scenario, the observed divergence of  $R_0$  in strong eld is explained by postulating that B induces localization of the electrons. However, applying this reasoning to the 3 sam ples in Fig. 3, we would conclude that a modest B is su cient to trigger the localization in clean sam ples, but very intense elds are needed in dirtier sam ples. This in plies that disorder and eld act in opposition to bring about localization, which is in con ict with physical intuition. In addition, localization induced by B cannot lead to the singular divergence observed in  $R_0$  (Fig. 2). For these reasons, we believe that localization is not a viable explanation for the divergence in  $R_0$ .

#### VI. DISCUSSION

In the absence of Zeem an splitting and electronelectron interaction, the n = 0 LL is 4-fold degenerate corresponding to the (physical) spin degeneracy indexed by = 1 and the K and K<sup>0</sup> valley degeneracy indexed by = 1. At = 0, the energy of the n = 0 LL, E<sub>s</sub>, is zero. The e ect of interaction in producing a brokensymmetry ground state has been investigated by several groups. To discuss our experiment, it is convenient to distinguish 2 di erent theoretical scenarios for the n = 0 LL.

In one scenario, the Q uantum H all Ferror agnet (Q HF) models, the exchange energy  $E_{ex}$  B leads to ferromagnetic polarization of the physical spins [7, 8, 10, 12,

17]. This produces a spin gap in the bulk without a ecting the valley degeneracy, i.e.  $E = (B + E_{ex})$  with B the Bohrm agneton. Near the edge of the sam ple, the residual valley degeneracy is lifted by the edge potential. An important consequence of the QHF scenario at = 0is the existence of spin-ltered counter-propagating edge (CPE) modes which result in a residual conductance of  $2e^2 = h$  regardless of the magnitude of the spin gap in the bulk [12, 17, 18]. [In principle, the CPE modes are not present if the exchange polarizes instead the valleys to produce the bulk gap (this involves the same exchange energy  $E_{ex}$ ). However, most investigators favor the spinpolarization scenario in graphene because it is augmented by the Zeem an energy <sub>B</sub> B (the valley-polarization seenario is also called the QHF following the original usage [20] in quadratic, bilayer G aA s-based devices).]

In the second scenario, called m agnetic catalysis [11, 13, 14, 15, 16], the eld component  $B_2$  norm alto the graphene sheet triggers electron-hole condensation. The instability introduces a mass term to the Dirac equation which leads to the order parameter [13, 14, 15] h i= (j <sub>A</sub> Ĵ  $j_B \hat{f}$ ), where A and в are the wave functions of electrons of spin and valat sites A and B, respectively. The instability { lev a solid-state realization of chiral-symmetry breaking in (2+1)D [21] { results in preferential occupation of, say, the A sublattice sites over the B sites, and drives the system into an insulating state. Signi cantly, the instability is strongest for n = 0.

The steep increase in R<sub>0</sub> vs. H sst reported in Ref. [19] in plies that at large H , the ground state at the D irac point has a resistance at least 20 times larger than the quantum h=e<sup>2</sup>. A lthough the measurements were limited to R<sub>0</sub> < 0.3 M , the uptum appeared to diverge at a critical eld H<sub>c</sub>, suggestive of a singular eld dependence. The ndings are clearly at odds with the existence of CPE modes (see, how ever, the results in Ref. [18]).

In the present report, we have extended by a factor of 200 the range of resistance m easurem ents and shown that, at 0.3 K, the increase in  $R_0$  is truly divergent as well as singular. Moreover, this behavior has been observed in all samples investigated to date by us in high elds. The evidence am assed clearly establish that the high-eld ground state at the D irac point is a true insulator (at least for samples prepared on a SiO<sub>2</sub> substrate). Ipso facto, the CPE m odes do not exist in the insulating state. How ever, our results do not preclude them at low elds.

Lately, several groups have considered how the CPE modes are a ected by intense ekd. A very interesting possibility is that an intense ekd destroys the CPE modes in a ekd-induced transition. It has been pointed out to us that the CPE modes are not protected against 2-particle exchange scattering with spin ip [22]. As the exchange energy increases with B, the increased scattering rate could lead to a gap in the edge modes.

In the magnetic catalysis scenario, G orbar et al. [15] recently considered the competition between the mass gap h i and the spin gap (augmented by Zeem an energy)

and inferred that CPE states exist only above a critical eld B  $_{\rm cr}$  .

Shim shoni et al. [23] have proposed that scattering o m agnetic in purities can lead to strong localization of electrons in CPE m odes which can m im ic a KT transition. However, this scenario needs to be reconciled with the observed nearly activated behavior of R<sub>0</sub> as well as the variation of H<sub>c</sub> with V<sub>0</sub> in di erent sam ples.

### VII. APPENDIX

N ear the D irac point, resistance traces are strongly distorted when the Ohm ic heating P exceeds 10 pW at bath temperatures  $T_b$  below 1 K.As examples, we plot in Fig. 7 resistance traces (with I xed). In Panela, the inferred curve of  $R_{xx}$  vs.  $V_g$ , m easured with B = 31 T, I = 10 nA and T = 0.3 K, shows a pronounced dip near the D irac point caused by self-heating instability (the true  $R_0$  exceeds 10 M ). Panelb shows  $\setminus R_0$ " vs B m easured at xed I. In the curve for K23 (at 5 K), self-heating reverses the trend of  $R_0$ . The downtum is avoided when I is decreased to 1 nA, but the m easured curve (in K22 at 0.3 K) is still greatly suppressed from the true divergent pro le.



FIG. 7: (color online) Spurious features caused by sample self-heating in graphene. Panel (a) shows a gate-sweep measurement at T = 0.3 K of R<sub>xx</sub> vs. V<sub>g</sub> in K52, with I xed at 10 nA (dc). At B = 31 T (red curve), severe self-heating inverts the peak at the D irac point (as shown in Fig. 1, R<sub>0</sub> actually exceeds 40 M ). Heating e ects are less severe in the 20-T curve. Panel (b) displays curves of  $R_0$ " vs. B measured in Sam ples K22 (at 0.3 K) and K23 (at 5 K) with I xed at 1 and 10 nA (dc), respectively. W hen R<sub>0</sub> > 0.2 M , self-heating produces the spurious shoulders and broad peaks, whose positions and shapes depend on I.

Figure 8 is a schematic of the measuring circuit em – ployed in the ultralow-dissipation technique. A nom inally constant ac voltage (40 V) of frequency 3 Hz is applied across the sample in series with a 100-k bu er resistor. The current passing through the sample is measured by a K eithley picoam meter whose output is phase-



FIG. 8: (color online) Schematic of the low-dissipation, voltage-regulated circuit used in the experiment. Lock-in (am pli er) A produces a regulated voltage em f (3 H z) that is reduced to an am plitude of 40 V by a 100:1 voltage divider. The signal goes through a liter, a bu er resistor (100 k) and a low-pass liter before entering the dewar. The AC current passing through the graphene sam ple is measured by the picoam meter (K eithley), whose output is phase-detected by Lock-in A. The longitudinal voltage V<sub>xx</sub> and H all voltage V<sub>xy</sub> are phase-detected by Lock-ins V<sub>1</sub> and V<sub>2</sub>, respectively, after transmission through a bank of - liters and high-im pedance (100 M) pre-am pli ers. As show n, all w ires entering the dewar are bu ered by 1 k nichrom e thin- Im ceram ic resistors. The inset (low er left) shows Sam ple J18.

detected by the lock-in ampli er A. Sim ultaneously, the longitudinal voltage  $V_{xx}$  and H all voltage  $V_{xy}$  are phasedetected by 2 other lock-ins. As shown, all wires entering the dewarare litered and bu ered to exclude extraneous RF signals which may be a potential source of sample heating.

Using the ultralow-dissipation technique, we completely avoid the therm al runaway problems illustrated in Fig. 7. At selected edds, we have performed I-V measurements to check that self-heating is not skewing the results even at our lowest T (0.3 K). Figure 9 shows curves of I vs.  $V_{xx}$  at the D irac point in K 52 at T = 0.3 K with H xed at 20 and 24 T. The linearity im plies that self-heating is not observable up to a bias voltage of 2 m V. Since all the curves displayed in the main text were taken with a bias of 40 V, we are comfortably within the 0 hm ic regime.

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FIG. 9: (color online) The current-voltage curves m easured at the D irac Point ( $V_g = V_0$ ) in Sam ple K 52 at T = 0.3 K at 2 the elds H = 20 and 24 T (using the circuit in Fig. 8). The linearity of I vs.  $V_{xx}$  in plies that, at these elds, self-heating is not observable at these power-dissipation levels (the dashed lines are guides to the eye).

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